

Towards Accurate Yield Analysis for Real-life Photonic Integrated Circuits

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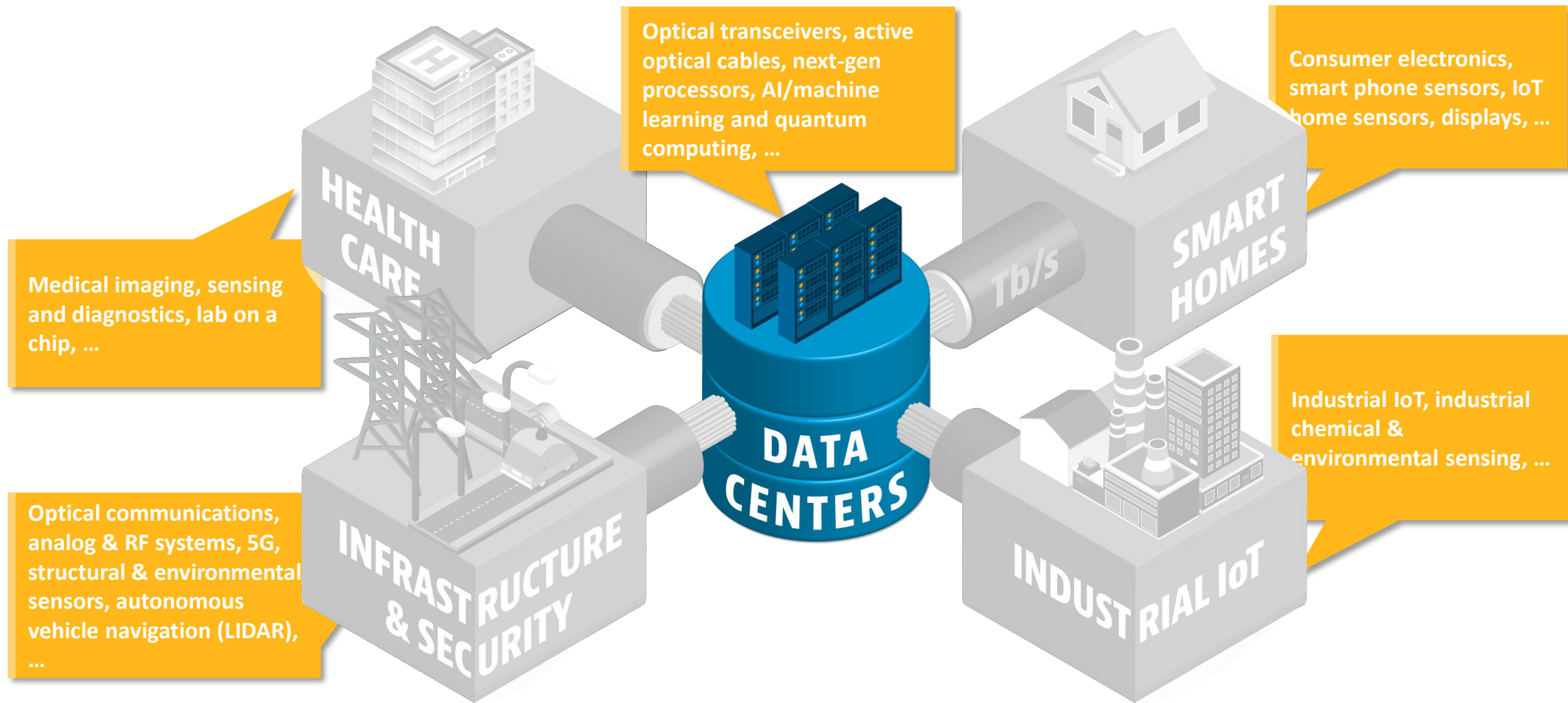
/ Abstract

Photonic Integrated Circuits (PICs) are pervasive in modern technology and enable everything from 5G/6G communications to taking the next big step in quantum computing. For PICs to be successful, we need to equip the photonic circuit designer with the necessary tools to create robust and manufacturable designs for their circuits. Fabricated photonic circuits are always different from their nominal design due to variations in the foundry process as well as SOI chip variations. As a photonics designer, it is important to understand how these variations affect the expected output and hence the yield. Statistical simulations provide insight to these variations. These variations in fabricated photonic circuits are often spatially correlated and so the statistical simulation must be layout aware and account for the spatial correlation between the different circuit elements. However, manufacturing variability is just one of the many challenges faced by a photonic circuit designer. Thermal effects from the drivers in the electronic IC, distortions in the electrical driving signal due to loading effects, and RF losses from packaging can all affect the yield of a real-life PIC. To address these challenges, we need compact models that can capture these effects and solvers that can accurately predict yield with electro-optical co-simulation. This presentation will focus on the research and development at Ansys, which is pioneering PIC simulation and the PIC design ecosystem.

Outline

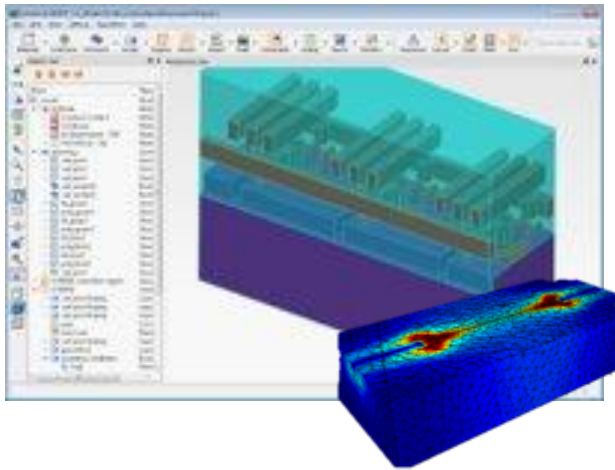
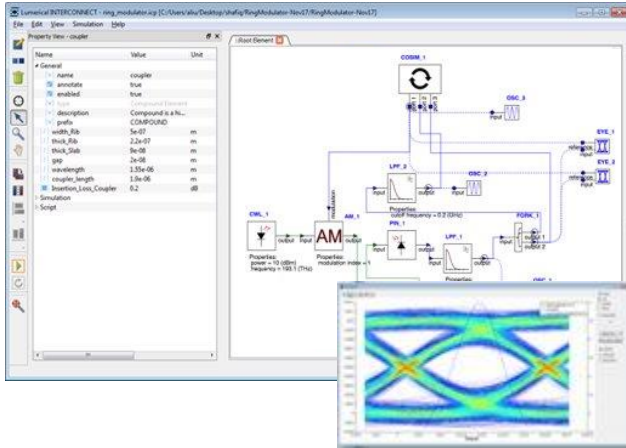
- Photonic integrated circuits (PICs) are pervasive in modern day technology
- Accurate yield analysis critical to the success of PIC designers
- Need to address an array of challenges:
 - Statistical variations + spatial correlation
 - Thermal effects on PIC
 - Electro-optical co-simulation – EPDA design flows
 - Source (laser) modeling for PIC simulations
 - Accurate compact model generation

Photonics is Everywhere, and Growing!



Ansys Lumerical Overview

A comprehensive set of tools and features for photonics



Photonic Integrated Circuit Simulation

INTERCONNECT Photonic Integrated Circuit Solver
Photonic Verilog-A Platform
CML Compiler Photonic Model Development

Photonic Multiphysics Simulation

FDTD 3D Electromagnetic Solver
MODE Waveguide Simulator
CHARGE 3D Charge Transport Simulator
HEAT 3D Heat Transport Solver
DGTD 3D Electromagnetic Solver
FEEM Waveguide Solver
MQW Quantum Well Gain Solver
STACK Optical Multilayer Solver

Interoperability, HPC & Cloud features

HPC & Cloud

HPC clusters, AWS, Azure, schedulers, ...

Automation APIs

Matlab, Python, Lumerical Script

Tool Integrations

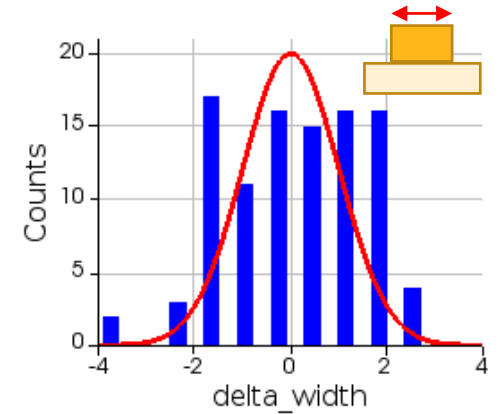
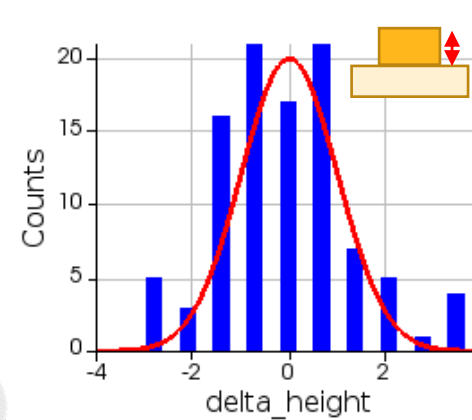
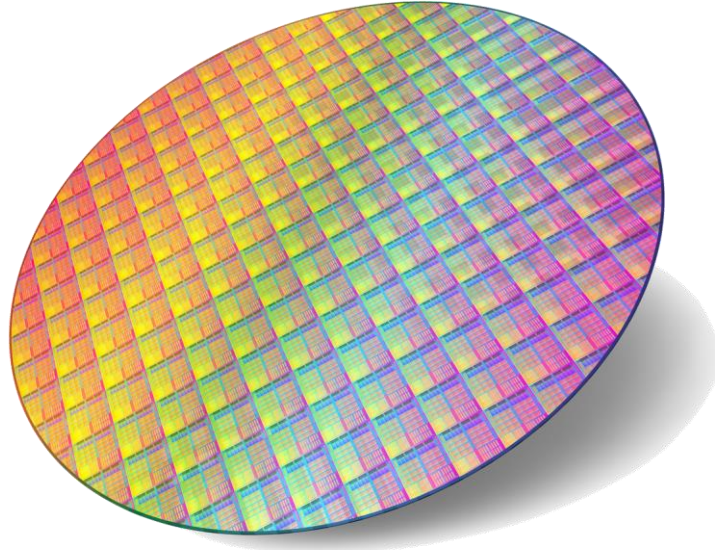
IPKISS, Klayout, Matlab, Tanner, Virtuoso, ADE, Zemax

Foundry Support

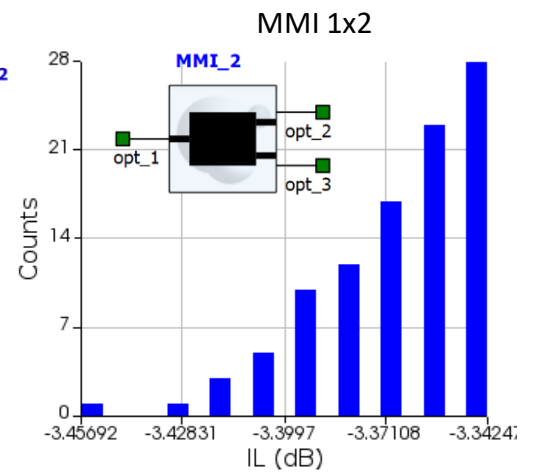
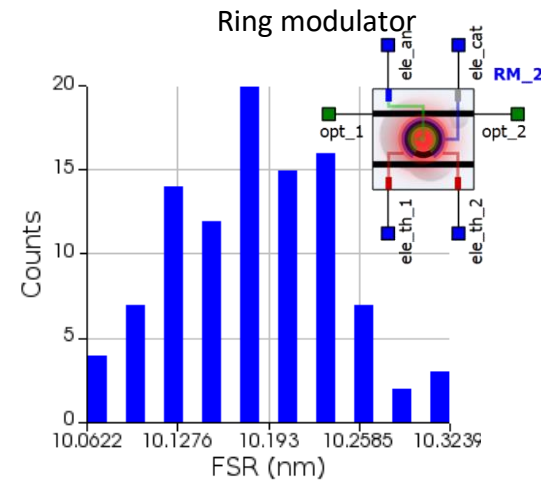
AIM, AMF, CompoundTek, HHI, imec, SMART, TowerJazz

Manufacturing Variability : Why Yield Analysis?

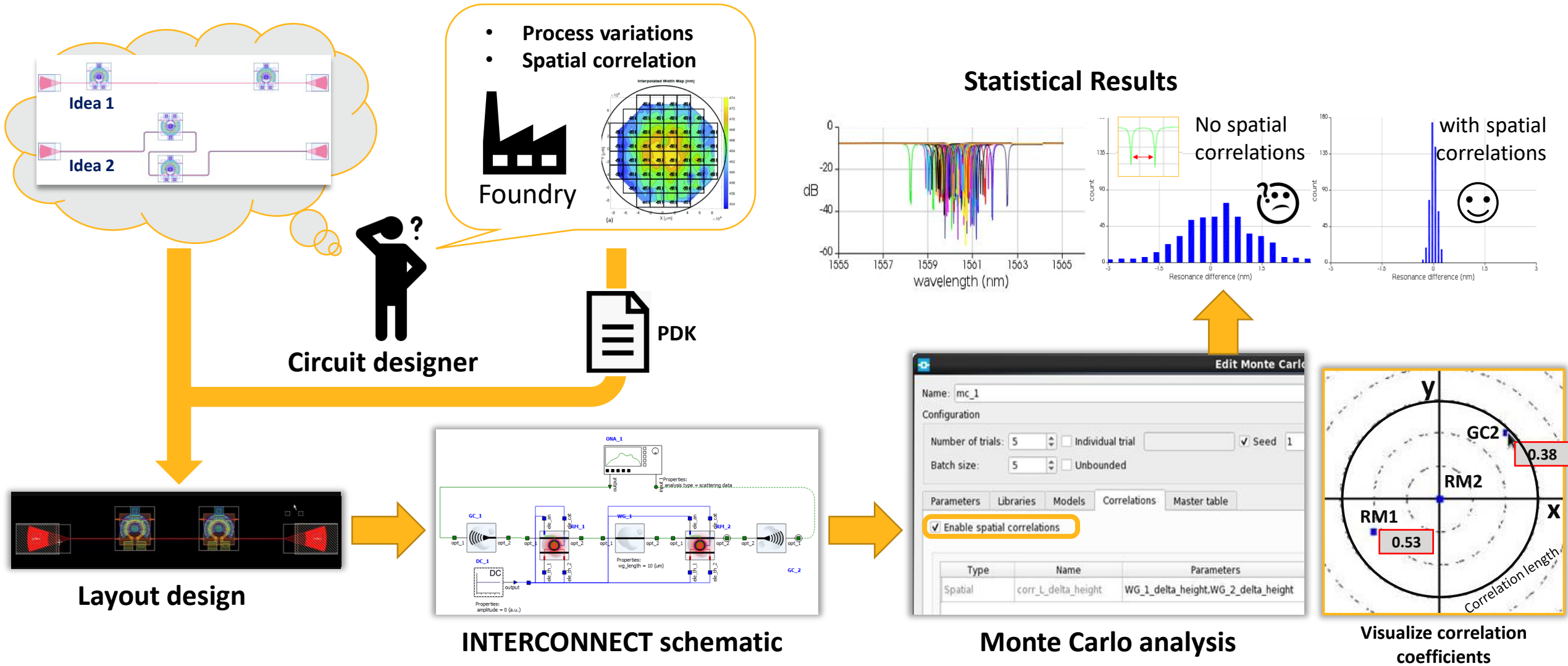
- Introduces project risk
- Process variability
 - Wafer height
 - Waveguide width
 - Side wall angle
 - Doping
 - Etc



- Circuit designers want to know what to expect.
- Best/worst case scenarios (corner analysis)
- Yield (Monte Carlo analysis)

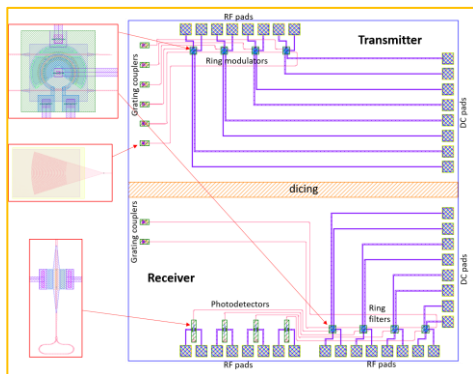


Modeling Spatial Correlation



Thermally Aware PIC Simulation

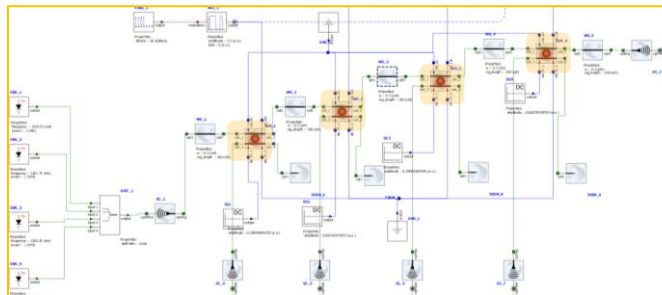
Layout



Netlist

import

INTERCONNECT schematic



Monte Carlo analysis

Edit Monte Carlo analysis

Name: Monte Carlo analysis

Configuration

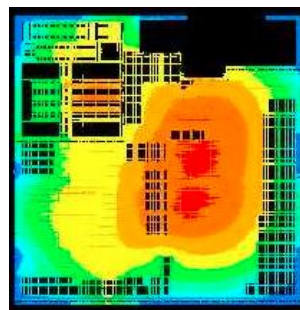
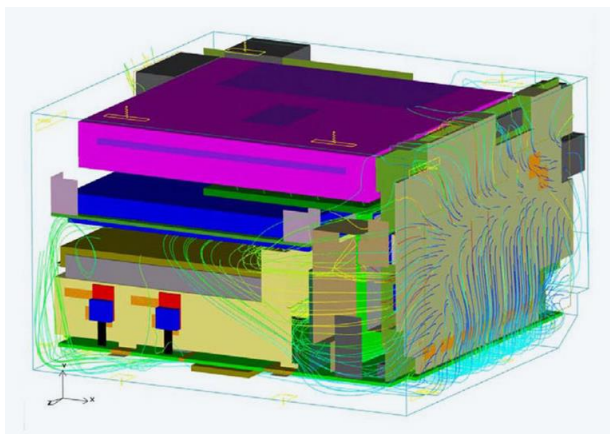
Number of trials: 10 ☐ Individual trial ☒ Seed 1

Batch size: 16 ☐ Unbounded

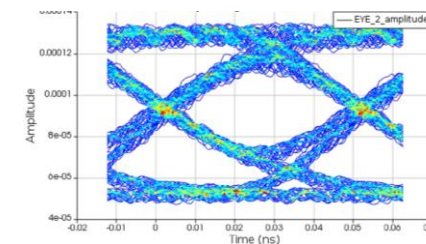
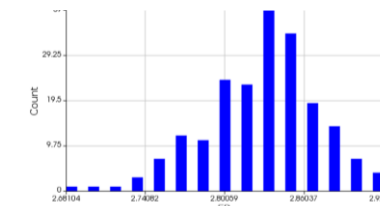
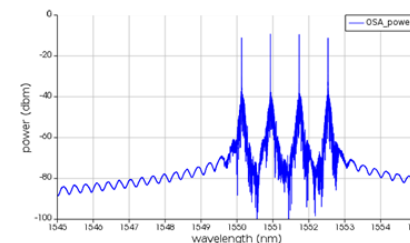
Parameters Libraries Models Correlations Master table

☒ Enable spatial correlations

Type	Name	Parameters	Value
Spatial	corr_1_delta_...	MMI_1_delta_height.WG_1_...	0.003m
Spatial	corr_1_delta_...	MMI_1_delta_width.WG_1_...	0.002m
Custom	new_coorela...	WG_1_delta_loss.new_par...	0

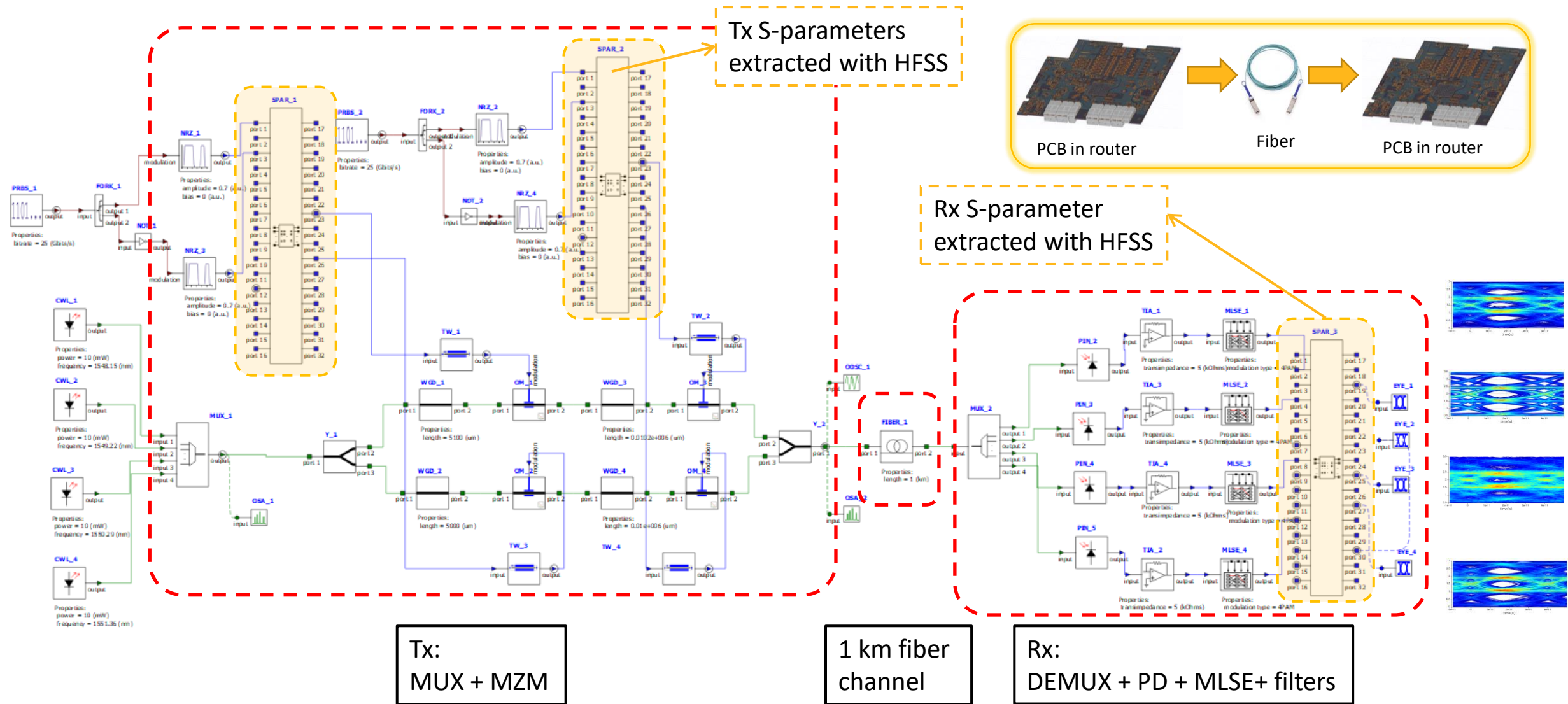


Temperature Map



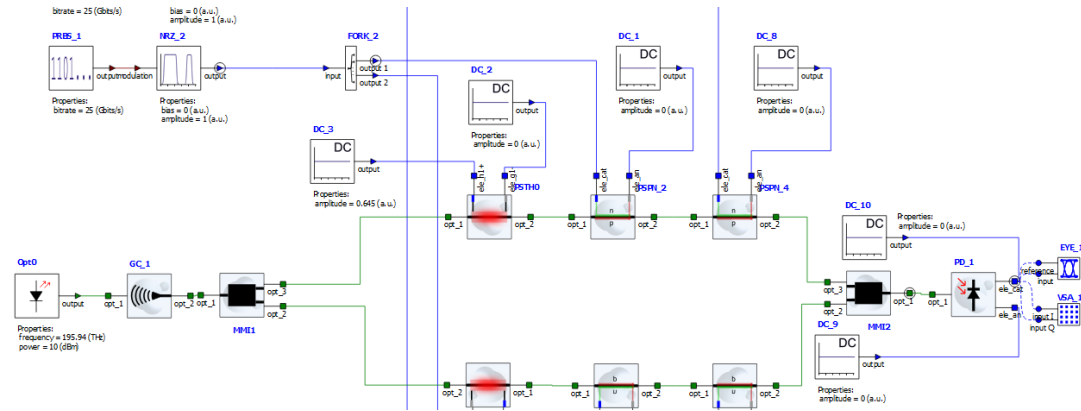
Thermal Simulation in ANSYS Icepak

System Level Simulation with HFSS and INTERCONNECT

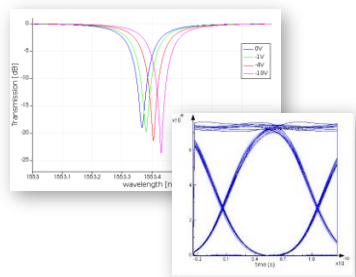


EPDA Design Flows

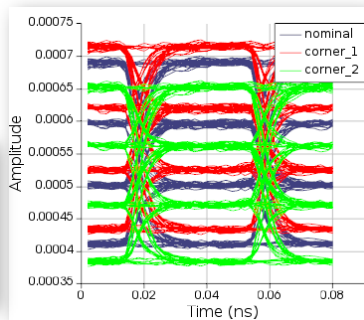
Ansys Lumerical INTERCONNECT platform



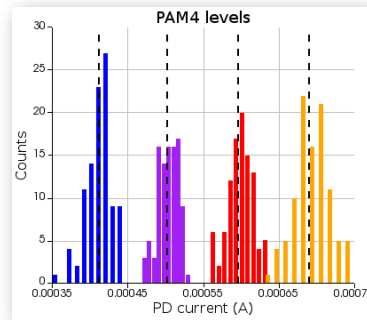
Frequency and time domain simulation



Corner analysis

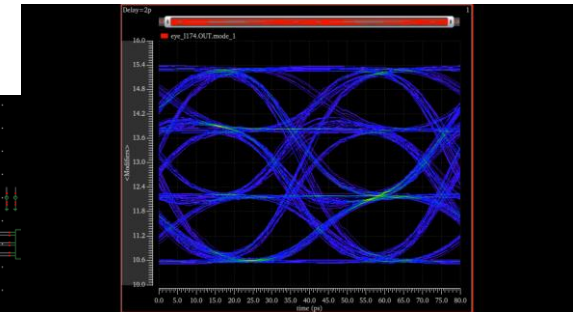
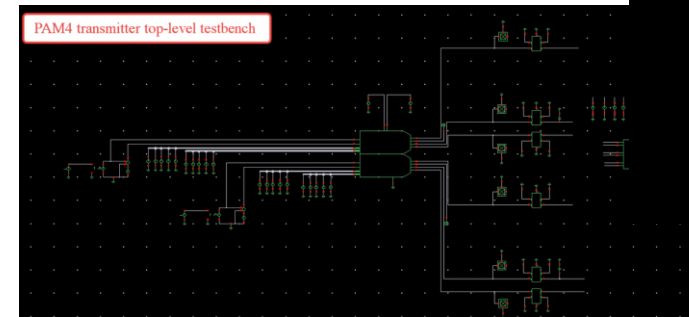


Monte Carlo analysis

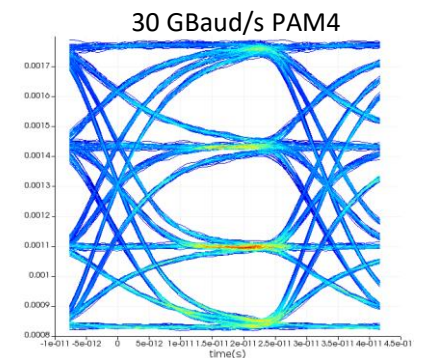
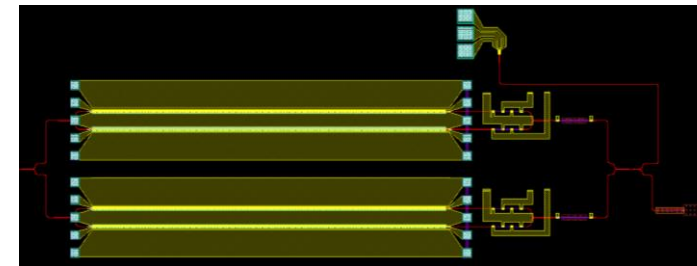


EPDA Design Flows

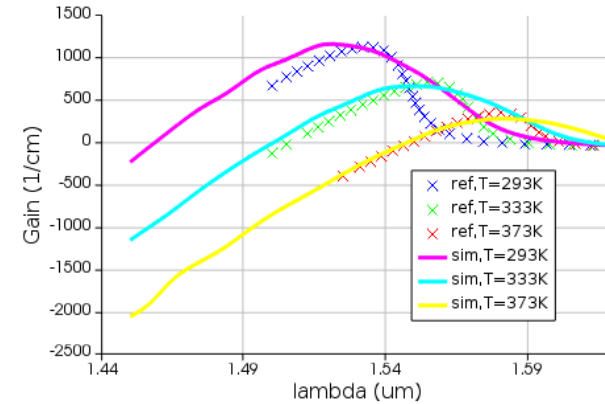
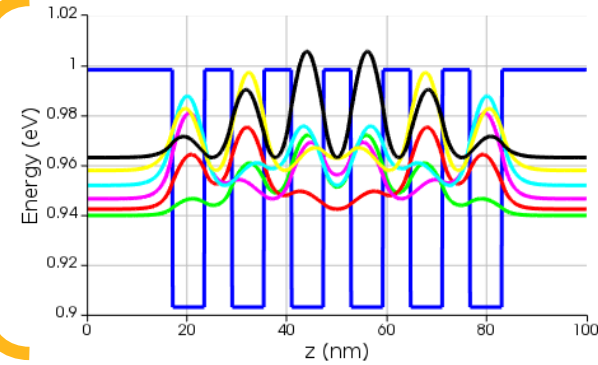
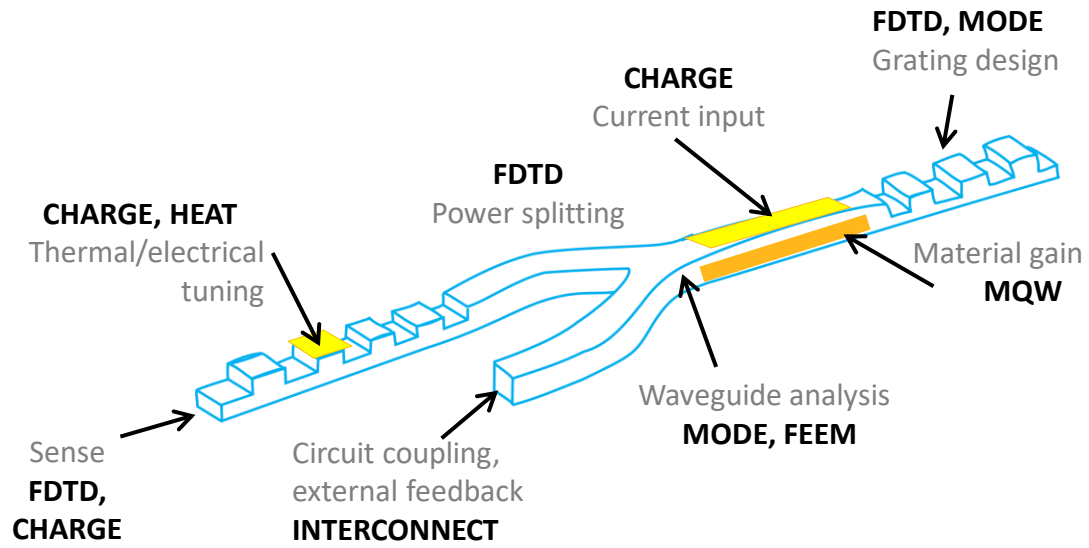
cadence



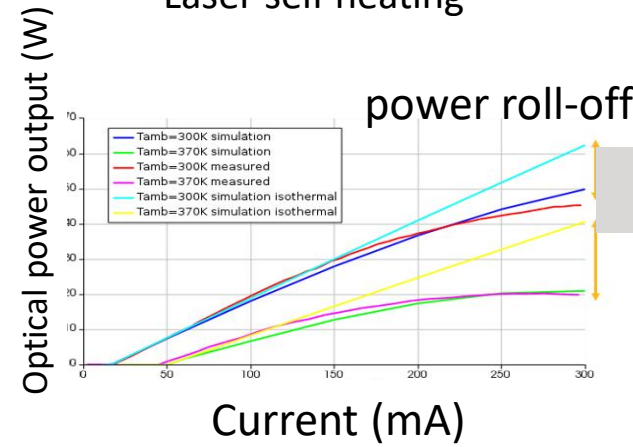
Mentor Graphics®



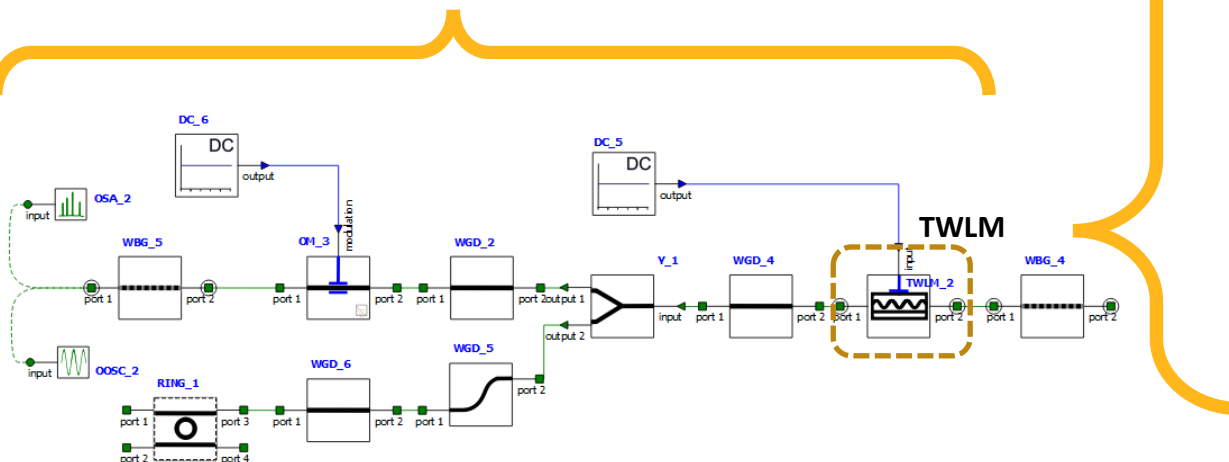
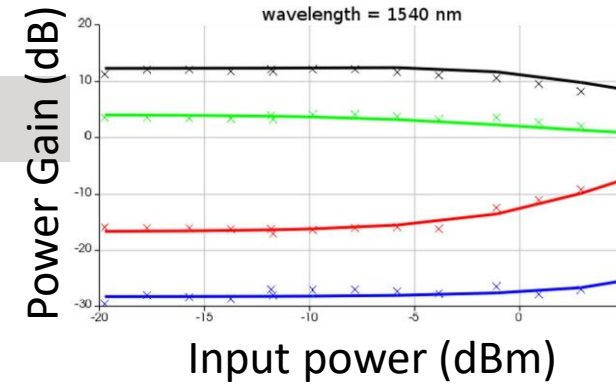
Ansys Lumerical Simulation Tools for Lasers and Gain



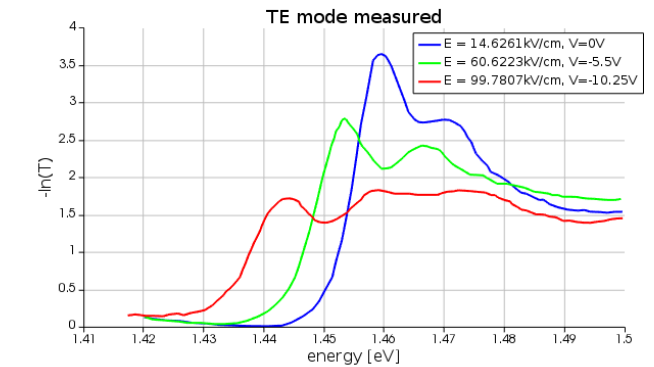
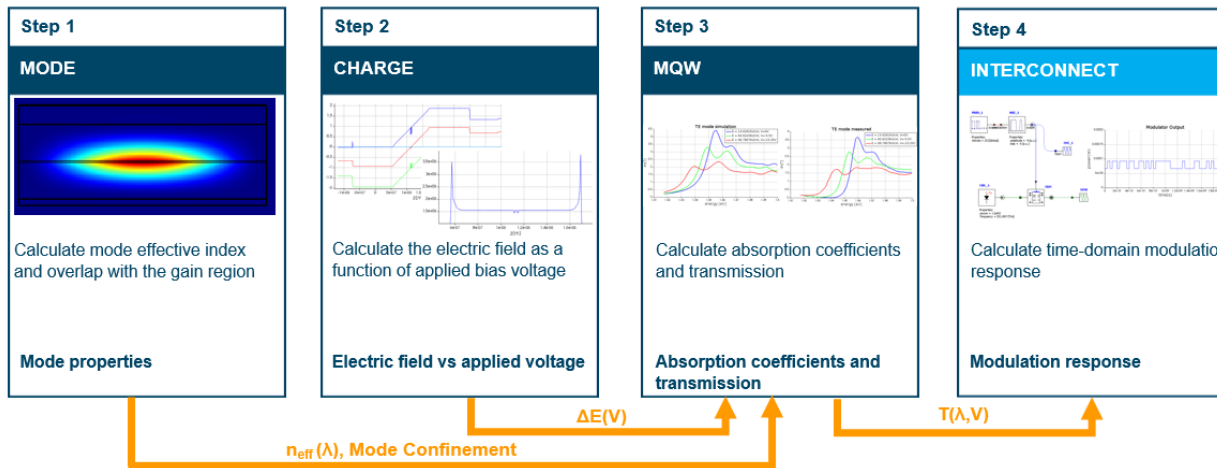
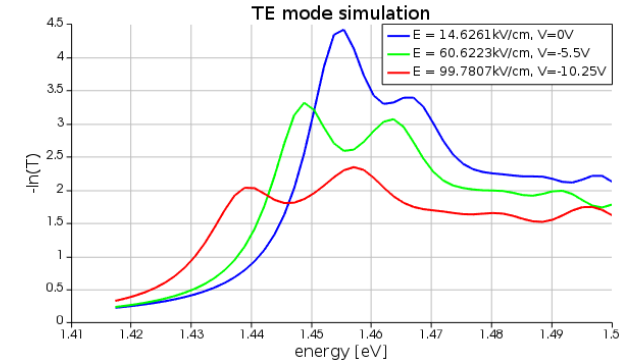
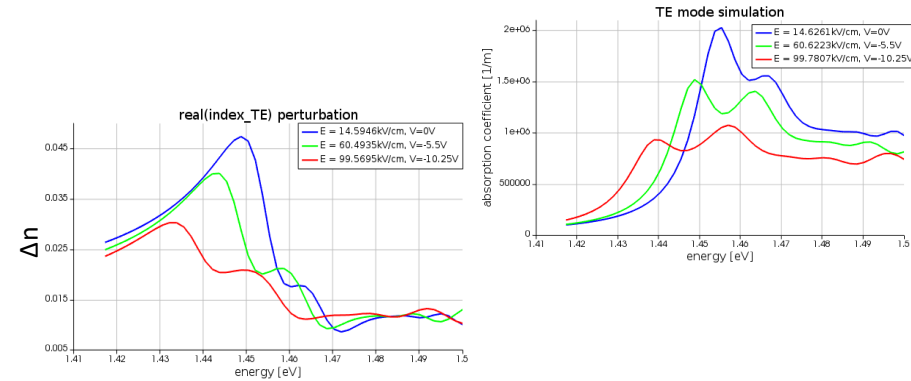
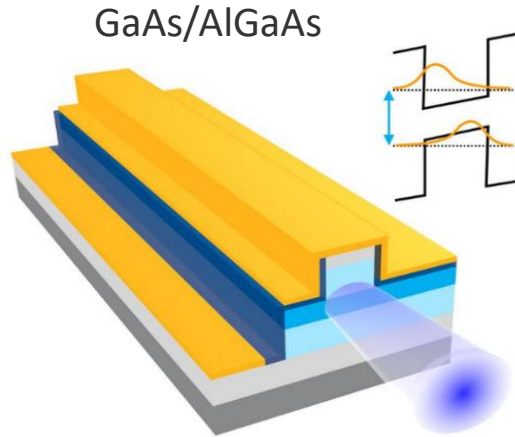
Laser self heating



Fraunhofer HHI
Calibrated SOA Compact Model



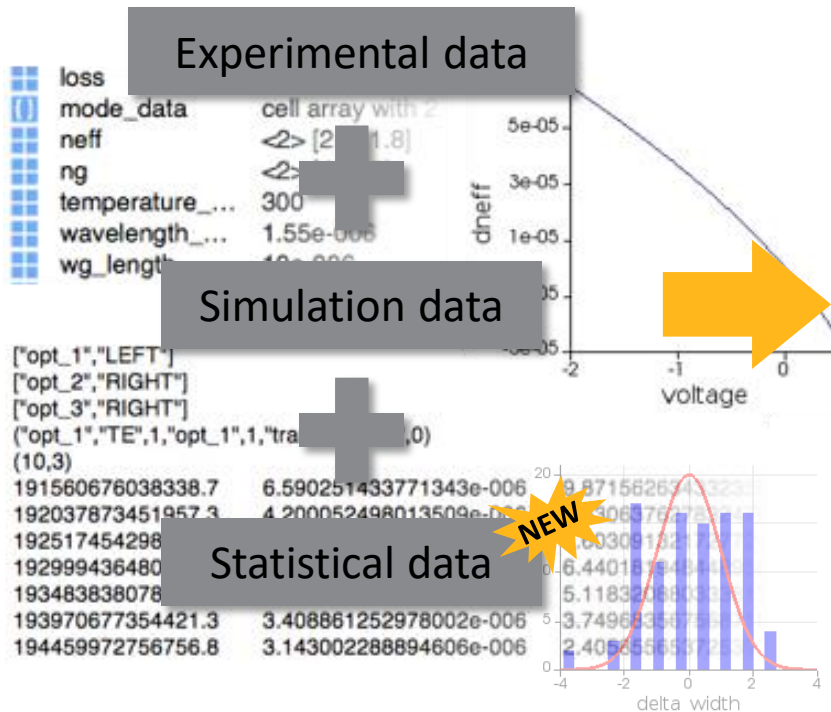
QCSE-based Electro-Absorption Modulator (EAM) Simulation



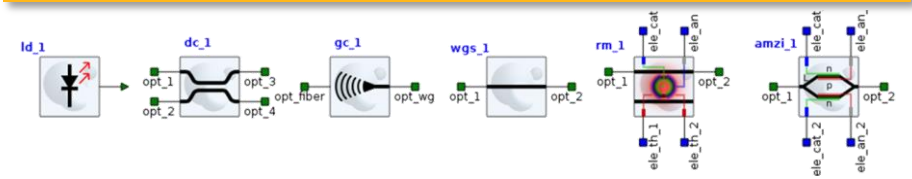
Reference: C.Y.-P. Chao and S. L. Chuang, Phys. Rev. B, 48, p. 8210, 1993.

CML Compiler : Enabling Accurate Photonic Compact Models

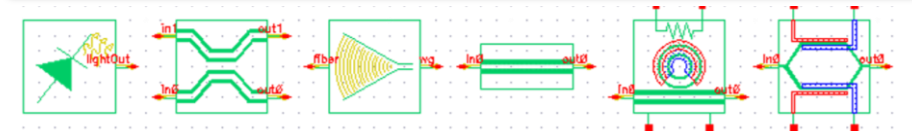
- Automates generation of photonic compact model libraries



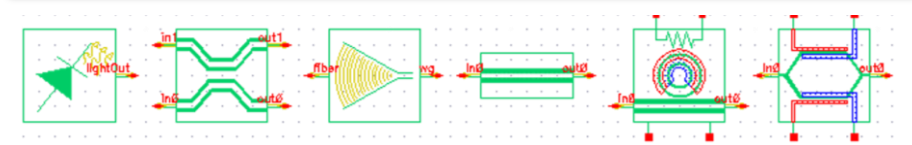
INTERCONNECT compact models (statistical)



Virtuoso symbols



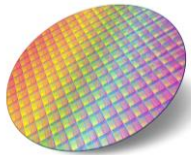
Photonic Verilog-A models (Virtuoso)



Compact Model Generation with CML Compiler

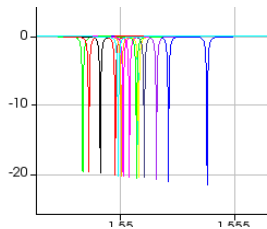
Statistical parameters

Physical



Width variability
Height variability

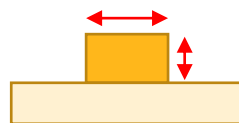
Performance



FSR variability
Peak λ variability

CML Compiler input data

Corners



Narrow

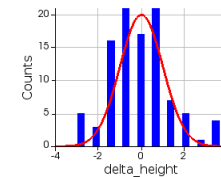


Wide

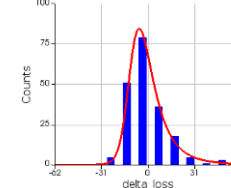
Other!

Distribution data

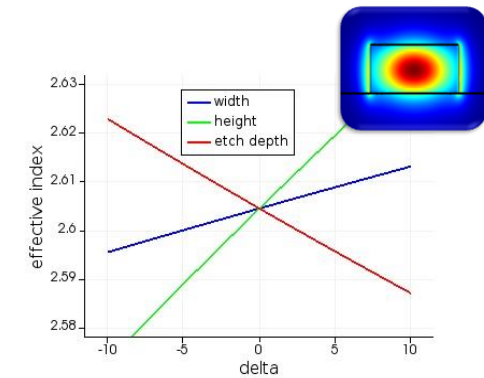
Gaussian



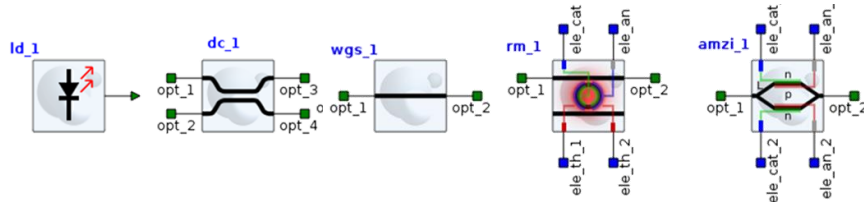
Pearson IV



Model sensitivity data



CML Compiler outputs



- ✓ Compact models with statistical parameters
- ✓ Supports spatial correlation and thermally sensitive
- ✓ Enabled for statistical simulation (INTERCONNECT and Virtuoso)

 **Ansys**

